

Please amend the subject application as follows:

IN THE SPECIFICATION:

On page 1, lines 1-2, change the title to "ELECTRONIC DEVICE FOR A LITHOGRAPHY MASK CONTAINER, SEMICONDUCTOR MANUFACTURING SYSTEM, AND METHOD".

On page 1, lines 4-10, delete the Related Application paragraph:

~~Related Application~~

~~The present invention is related to the commonly assigned United States application "Electronic device for a wafer container, wafer manufacturing system, and method" by Alain Charles et. al., identified by attorney docket number SC0098WD.~~

On page 22, lines 1-2, change the title to "ELECTRONIC DEVICE FOR A LITHOGRAPHY MASK CONTAINER, SEMICONDUCTOR MANUFACTURING SYSTEM, AND METHOD".